AN 136:77001 CA ED Entered STN: 24 Jan 2002 TI Integrated microchip lasers having regulatory function of frequency IN Huang, Yidong, Chen, Xueyuan, Tu, Zhaoyang, Luo, Zundu PA Fujian Inst. of Matter Structure, Academia Sinica, Peop. Rep. China SO Faming Zhuanli Shenqing Gongkai Shuomingshu, 8 pp. CODEN: CNXXEV DT Patent LA Chinese IC ICM H01S003-16 ICS H01S003-10 CC 73-10 (Optical, Electron, and Mass Spectroscopy and Other Related Properties) Section cross-reference(s): 75 FAN.CNT 1 APPLICATION NO. DATE KIND DATE PATENT NO. CN 1999-125311 19991130 20010606 PI CN 1298217 Α 19991130 PRAI CN 1999-125311 AB The integrated microchip laser is manufactured by determining the frequency-doubling or frequency-mixing phase-matched direction of nonlinear optical crystal substrate, growing laser crystal microchip on the end face vertical to the phase-matched direction, and coating medium membrane. The substrate is GdxY1-xAl3(BO3)4, Ca4GdxY1-xO(BO3)3, Gd2xY2(1-x)(MoO4)3, or LaSc3(BO3)4 (x = 0-1). The crystal microchip was formed by part or complete replacement of Gd3+, Y3+, or La3+ with Nd3+, Er3+, Pr3+, or Yb3+, etc. The substrate may also be LiNbO3, and its laser crystal microchip is RE3+:MgO:LiNbO3 or RE3+:ZnO:LiNbO3 (RE = Nd, Er, Pr, Yb, or other rare earth ion). One passive Q-regulatory crystal microchip may be formed by doping Cr4+ before formation of laser crystal microchip. ST integrated microchip laser manuf, nonlinear optical crystal IT Nonlinear optical materials Solid state lasers (integrated microchip lasers having regulatory function of frequency) IT Rare earth metals, uses RL: TEM (Technical or engineered material use); USES (Uses) (ions, integrated microchip lasers having regulatory function of IT 14913-52-1, Neodymium ion (Nd3+), uses 15723-28-1, Chromium ion (Cr4+), frequency) uses 18472-30-5, Erbium ion (Er3+), uses 18923-27-8, Ytterbium ion (Yb3+), uses 22541-14-6, Praseodymium ion (Pr3+), uses RL: TEM (Technical or engineered material use); USES (Uses) (integrated microchip lasers having regulatory function of frequency) IT 12031-63-9, Lithium niobium oxide (LiNbO3) 13813-76-8 130773-05-6 RL: DEV (Device component use); USES (Uses) (substrate; integrated microchip lasers having regulatory function of frequency)